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INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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of Sheet 1

Complete If Known					
Application Number	09/943,199				
Filing Date	August 29, 2001				
First Named Inventor	Kristy A. Campbell				
Art Unit	2818				
Examiner Name	D. Vu				
Attorney Docket Number	M4065.0704/P704				

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Exeminer	Cite	Document Number	Publication Date	Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant	
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Present Application, not prior art

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Application Number	09/943,199				
Filing Date	August 29, 2001				
First Named Inventor	Kristy A. Campbell				
Ari Unit	2818				
Exeminer Name	D. Vu				
Attorney Docket Number	M4065.0704/P704				

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	STATEMENT	3Y /	APPLICANT	First Named Inventor	Kristy A. Campbell	
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				Examiner Name	D. Vu	
Sheet	4	of	5	Attorney Oocket Number	M4065.0704/P704	

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^{*}EXAMINER: Initial if reference considered, whether or not clistion is in conformance with MPEP 609. Order line through clistion if not in conformance and not considered. Include copy of this form with next communication to applicant

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¹ Applicant's unique citation designation number (optional). 2 See attached Kinds Codes of USPTO Patent Documents at mmw.uspin.gov or MPEP 901.04. 3
Enter Office that Issued the document, by the two-tester code (WIPO Standard ST.3). "For Japanese patent documents, the indication of the year of the reign of the Emporer must precede the application number of the patent document." Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. "Applicant to to place a check mark here if English tanguage Translation is attached.

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Complete If Known Application Number 09/943,199 INFORMATION DISCLOSURE STATEMENT BY APPLICANT Filing Date August 29, 2001 First Named Inventor Kristy A. Campbell Group Art Unit 2818 (use as many sheets as necessary) Examiner Name D. Vu 5 5 M4065.0704/P704 of Attorney Docket Number

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Examiner Cite No.1		Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc), date, page(s), volume-issue number(s), publisher, city and/or country where published.	7
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Examiner Initials	Cite No.	Document Number Number-Kind Code ² (# known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
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Applicant's unique citation designation number (optional). ³ See attached Kinds Codes of USPTO Patent Documents at www.uspio.gov or MPEP 901.04. ³
Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3) *For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the application number of the patent document. ³ Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST 16 if possible. ⁴ Applicant is to place a check mark here if English tanguage Translation is attached.

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8 Attorney Docket Number Sheet 2

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Examiner C/ () Date	12/08/04
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